Setup and motivation large or small @ classical system of Nidentical particles j=1,2,...,N positions  $K_1, \dots, K_N \in A_1 \subset \mathbb{R}^3$   $\mathbb{R} = (K_1, \dots, K_N) \in A_1^N$ momenta  $P_i$ ,  $P_i \in \mathbb{R}^3$ Description state  $P = (P_i, ..., P_N) \in \mathbb{R}^{3N}$   $P = (P_i, ..., P_N) \in \mathbb{R}^{3N}$  In the standard expression for the Helmholtz free energy  $F(\beta,H) = -\beta^{-1} \log \frac{Z(\beta_r H)}{C^N N!} \qquad C > 0 \text{ constant (usually } C = h^3)$   $\text{why?} \Rightarrow \text{any physical reasoning??}$ quantum

system - B-1 log Tr e-BH ~ - B-1 log Z(B,H) BUT F=-B-1 log Tr e-BH??

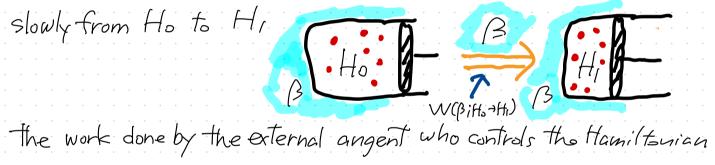
properties of Z(B,H)

Denergy expectation value

$$\langle H \rangle_{B,H} = -\frac{2}{\delta B} \log Z(B,H)$$

@ quasi-static work

a quasi-static isothermal process in which the Hamiltonian is changed



$$W(B; H_o \rightarrow H_l) = \frac{1}{B} \log 2(B, H_o) - \frac{1}{B} \log 2(B, H_l)$$

Standard premises for F(BiH) thermodynamics

 $F(\beta,H) = -\frac{1}{B}log[P Z(\beta,H)]$  with P independent of B

P-2 minimum work principle W(B; Ho+H1) = F(B,H1) - F(B,H0) F(B,H) = - [log[] Z(B,H)] with I independent of H

Defrom these two premices  $F(B,H) = -\frac{1}{3} \log [\Phi(N) Z(B,H)]$ 

更(N) is arbitrary statistical mechanics is useful with any 更(N) are there any physical premises that fix P(N)??

P=3 extensivity  $F_{TD}[T; \lambda V, \lambda N] = \lambda F_{TD}[T; V, N]$  implies  $\Phi(N) = (c'N)^{-N} \sim \frac{1}{(c'e)^{N} N!}$  only for N>21

the Sasa-Hiura-Nakagawa-Yoshida (SHNY) process and the third premise 4 B N, Ho B HL HR B in the SHNY process quasi-static isothermal proces NOT a standard equilbrium P-3 refined minimum work principle WSHNY = F(B, NL, HL)+F(B, NR, HR) - F(B, N, HD) &) the result from an explicit construction see below  $W_{SHNY} = \frac{1}{B} \log \frac{Z_0(B)}{N!} - \left\{ \frac{1}{B} \log \frac{Z_L(B)}{N_L!} + \frac{1}{B} \log \frac{Z_R(B)}{N_R!} \right\} \tag{$\star$}$ desired N dependent factor!! from (\*) and (\*\*) Zo(B)= SdRdPe-BHO F(B,N,H) = - 3 log Z(B,H) ZL(0)=SdRLdPLe-BHL ZZ(B)=JdRedPe e-BHP

B Ho BHL HIZ B Wuntrap 3 Burtrapping

Brocess trapping & Wtrap B Htrap. L Htrap. R Mall insertion Wfrap, Wuntrap can be evaluated from the standard relation

W(Bi Hinit > Hfin) = = log 2(BiHinit) - = log 2(BiHinit)

Horowitz, Parrondo 2011

Construction of a SHIVY process

Construction of a SHIVY process	
1 Trapping Hamitonian Htrap (R,P) = \( \sum_{\left(2m)} + Utrap (H_{\igc{j}}) \right) + \frac{1}{2} \sum_{\interpolenter} Vrep (1)	lt; -th/)
Utrap(H) Who deep minima in Al shor	trange vepulsion
equlibrium state $ \mathbb{Z}_{\text{trap}(B)} = \int dR dP e^{-BH trap} $ $ \simeq N! (3(B))^{N} $	(R,P)
trapping process Ha(R,P) = (I-d)Ho(R,P) + dHtrap(R,P)	$\alpha \in (0,1)$
trapping process $Ha(R,P) = (I-\alpha)Ho(R,P) + \alpha Htrap(R,P)$ start from Ho and change of slowly from 0 to 1,  (the system is in touch with heat both at B)  quasi-static isothermal process  What $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ standard  relation  see P. $= \frac{1}{B} \log Z_0(B) - \frac{N}{B} \log Z_0(B)$ By the system is in touch with heat both at B)  Hat $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ The system is in touch with heat both at B)  Hat $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ Standard  relation  See P. $= \frac{1}{B} \log Z_0(B) - \frac{N}{B} \log Z_0(B)$ By the system is in touch with heat both at B)  Hat $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ The system is in touch with heat both at B)  Hat $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ The system is in touch with heat both at B)  Hat $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ The system is in touch with heat both at B)  Hat $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ The system is in touch with heat both at B)  Hat $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ The system is in touch with heat both at B)  Hat $= \frac{1}{B} \log Z_0(B) - \frac{1}{B} \log Z_0(B)$ The system is in touch with heat both at B)	

Wall-insertion process

divde I into IL and IR by a thin wall

Wwall = 0

the state essentially does not change

untrapping process

the opposite of trapping

Htrap, I Htrap,

$$Wuntrap, L = \frac{NL}{B} \log 3(B) - \frac{1}{B} \log \frac{2L(B)}{NL!}$$

$$Wuntrap, R = \frac{NR}{B} \log 3(B) - \frac{1}{B} \log \frac{2R(B)}{NR!}$$

$$Wuntrap, R = \frac{NR}{B} \log 3(B) - \frac{1}{B} \log \frac{2R(B)}{NR!}$$

$$When total work needed for the SHNY process$$

$$Wshny = Wtrap + Wwall + Wuntrap, R$$

$$= \frac{1}{B} \log \frac{2O(B)}{N!} - \frac{N}{B} \log \frac{3(B)}{B} + \frac{NL}{B} \log \frac{3(B)}{NL!} + \frac{NR}{B} \log \frac{3(B)}{NR!}$$

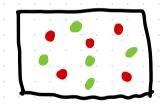
= [log Zo(B) - plog ZL(B) - plog Ne! = the desired relation

## What does it precisely mean that classical particles are identical

· Only dynamical properties the same mass, the same potential, the same interactions.

quantum case the basic symmetry of the Hilbert space · the identity guarantees that the wall insertion process is reversible.

what happens if the particles are identical but distinguishable?



- nothing changes if we simply ignore the colors and analyze quasi-static work the same factor N!
  - · there may be potentials or interactions that distinguish the colors

the particles are no longer identical.

